## Selective Substitution of $Hex_2SiFCl$ for the Preparation of Polymers with Two Different Alternate $\pi$ -Electron Systems Linked by $Hex_2Si$ Units

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Dedicated to Professor Hubert Schmidbaur on the occasion of his 70<sup>th</sup> birthday

Organosilicon polymers having a regular alternate arrangement of  $-\text{Hex}_2\text{Si}-\pi-\text{Hex}_2\text{Si}-\pi' (\pi,\pi'=\pi\text{-electron system})$  were prepared by successive treatment of  $\text{Hex}_2\text{SiFCl}$  with dilithiated  $\pi$ -conjugated compounds,  $\text{Li}-\pi-\text{Li}$  and  $\text{Li}-\pi'-\text{Li}$  ( $\pi$  = diethynylanthracene, diethynylpyrene, diethynylcarbazole;  $\pi'$  = bithiophenediyl, terthiophenediyl). UV-vis absorption spectra and cyclic voltammograms of the resulting polymers indicated that the two  $\pi$ -electron systems,  $\pi$  and  $\pi'$ , are electronically isolated, while the emission spectra indicated that energy transfer between the  $\pi$ -electron systems occurred in the excited states.

Key words: Organosilicon Polymers, Chlorofluorosilanes, Selective Addition